

Serial No. 10/016,562

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1252-430
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Chang-Lin Hsieh et al.

Serial No.: 10/016,562

Filed: 12/12/2001

Title: Process for Selectively Etching Dielectric Layers

Art Unit: 1765

Examiner: Deo, Duy Vu Nguyen

Docket No.: 004544/ALRT/ETCH/DICP

VIA FACSIMILE 703-872-9310

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

PETITION UNDER 37 CFR 1.36(a) AND AMENDMENT

Sir:

Applicants hereby petition the Assistant Commissioner to grant a two (2) month extension of time, up to and including Tuesday, November 30, 2004, in which to respond to the Office Action dated June 30, 2004 in the above-identified application. The extension fee in the amount of \$430.00 may be charged to deposit account No. 50-1047. In addition, any deficiencies may be charged to deposit account No. 50-1047.

In response to the Office Action dated June 30, 2004, the period therefore having been extended by a Petition therefore and payment of the extension fee, kindly amend the above-identified application as follows:

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01 FC:1252 430.00 DA
02 FC:1202 54.00 DA